

Search Notes

Application No.

09/321,518

Examiner

Wai-Sing Louie

Applicant(s)

GILTON ET AL.

Art Unit

2814

SEARCHED

Class	Subclass	Date	Examiner
438	618	4/28/2000	BES
216	41,47	5/1/2000	BES
118	64,666,	5/31/2001	WSL
118	667,500	5/31/2001	WSL
438	464,716	5/31/2001	WSL

INTERFERENCE SEARCHED

Class	Subclass	Date	Examiner
438	464,716,	11/21/2003	WSL
438	618	11/21/2003	WSL
118	64,666,	11/21/2003	WSL

**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
Photoresist, wafer, liquid, solvent, reaction chamber	5/1/2000	BES
wafer, semiconductor, photoresist, stripping, cleaning, removal	6/1/2001	WSL